

REMARKS

By this amendment, claim 19 has been amended. Accordingly, claims 19-22 are currently pending in the application, of which claim 19 is an independent claim.

Applicants respectfully submit that the above amendments do not add new matter to the application and are fully supported by the specification. Support for the amendment(s) and added claims may be found at least in Figure(s) 4A through 4G and at page 14, line 2 to page 17, line 13 of the specification.

Entry of the Amendments and Remarks is respectfully requested because entry of Amendment places the present application in condition for allowance, or in the alternative, better form for appeal. No new matters are believed to be added by these Amendments. In view of the above amendments and the following Remarks, Applicants respectfully request reconsideration and timely withdrawal of the pending objections and rejections for the reasons discussed below.

Rejections Under 35 U.S.C. § 102

Claims 19-21 stand rejected under 35 U.S.C. § 102(e) as being allegedly anticipated by U. S. Patent No. 6,323,051 issued to Shimada, *et al.* ("Shimada"). Applicants respectfully traverse this rejection for at least the following reasons.

Claim 19, as amended, recites *inter alia*:

"An active matrix display device, comprising... wherein the source/drain electrodes have a dual-layered structure of a transparent conductive layer and a metal layer, the metal layer being enclosed by the insulation film and formed on the transparent conductive layer, wherein the metal layer and the insulation film are etched for exposing a portion of the transparent conductive layer forming any one of the source/drain electrodes, and wherein the pixel electrode extends from the portion of the transparent conductive layer forming any one of the source/drain electrodes and is exposed through the opening portion of the insulation film."

Applicants respectfully submit that Shimada does not teach or suggest such features. Rather, Shimada discloses TFT 121 comprising a source metal film 106, a transparent conductive film 107, and a protective film 108, where the transparent conductive film 107 is formed on the source metal film 106 (See FIG. 5(c); See col. 2, lines 32-34). Additionally, Shimada does not show that the metal layer is etched for exposing a portion of the transparent conductive layer forming any one of the source/drain electrodes.

Accordingly, Applicants respectfully request withdrawal of the 35 U.S.C. § 102(e) rejection of claims 19-22. Since none of the other prior art of record discloses or suggests all the features of the claimed invention, Applicants respectfully submit that independent claim 19, and all the claims that depend therefrom, are allowable.

Rejections Under 35 U.S.C. § 103

Claim 22 stands rejected under 35 U.S.C. § 103(a) as being allegedly unpatentable over Shimada in view of U. S. Patent No. 5,895,692 issued to Shirasaki, *et al.* ("Shirasaki"). Applicants respectfully traverse this rejection for at least the following reasons.

As noted above, Shimada fails to teach or suggest the each and every claimed feature of the present invention as disclosed in claim 19. Shirasaki fails to cure the deficiencies of Shimada.

Accordingly, Applicants respectfully request withdrawal of the 35 U.S.C. § 103(a) rejection of claim 22. Since none of the other prior art of record, whether taken alone or in any combination, discloses or suggests all the features of the claimed invention, Applicants respectfully submit that claim 22 is allowable.

CONCLUSION

Applicants believe that a full and complete response has been made to the pending Office Action and respectfully submits that all of the stated objections and grounds for rejection have been overcome or rendered moot. Accordingly, Applicants respectfully submit that all pending claims are allowable and that the application is in condition for allowance.

Should the Examiner feel that there are any issues outstanding after consideration of this response, the Examiner is invited to contact the Applicants' undersigned representative at the number below to expedite prosecution.

Prompt and favorable consideration of this Reply is respectfully requested.

Respectfully submitted,

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